

#6/Reg. St.
Time1-17-03
P. Spruell**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the Application of:

Robert H. Havemann Docket No.: T1-27506
Serial No.: 10/001,472 Examiner: Wojciachowicz, E.
Filed: 11/01/01 Art Unit: 2815
FOR: INTEGRATED CIRCUIT HAVING A DOPED POROUS DIELECTRIC AND METHOD OF
MANUFACTURING THE SAME

REQUEST FOR EXTENSION OF TIME

Assistant Commissioner of Patents
Washington, DC 20231

Dear Sir:

Pursuant to 37 CFR 1.136(a), Applicant(s) respectfully petitions the Commissioner
for an extension of the shortened statutory period for response in the above-identified
Application.

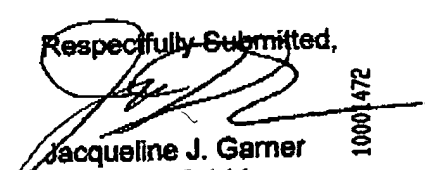
The fee for this extension is indicated below:

- ☐ One Month (\$110)
☒ Two Months (\$400)
☐ Three Months (\$920)
☐ Four Months (\$1,440)

Please charge the fee to deposit account no. 20-0668. Any further necessary
extension of time is hereby requested. Charge any and all fees to deposit account no. 20-
0668. An original and two copies of this sheet are enclosed.

Texas Instruments Incorporated
PO Box 855474, M/S 3999
Dallas, TX 75265
(214) 532-9348
Fax: (972) 917-4418

Respectfully Submitted,


Jacqueline J. Garner
Reg. No. 36,144**FAX RECEIVED**

DEC 13 2002

TECHNOLOGY CENTER 2800

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